

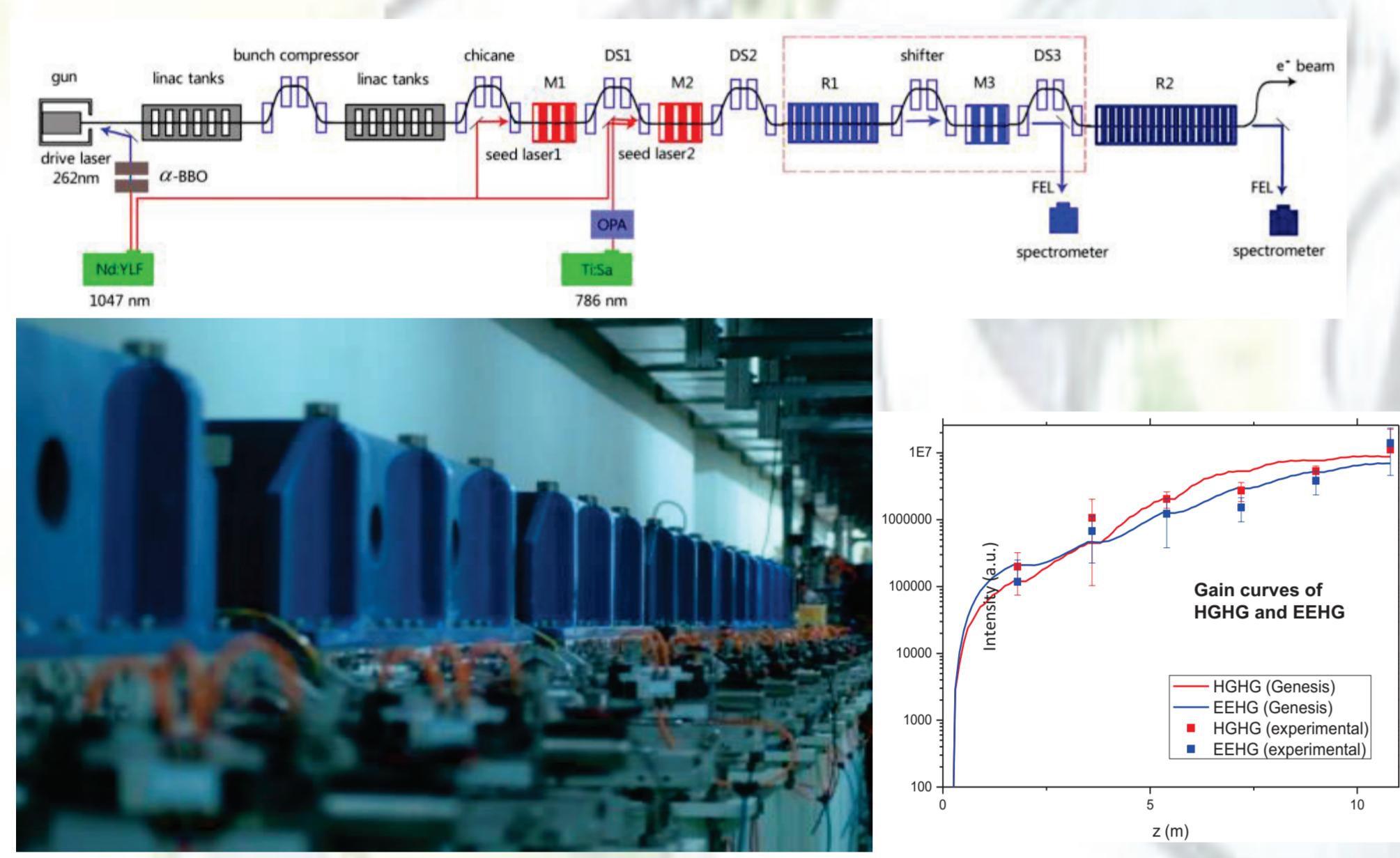


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## SDUV-FEL

A test facility for new FEL principles based on a 200MeV Linac, has been operated for 5 years at Jiading campus and got a series of important results. It will be closed when SXFEL starts operation in 2017.

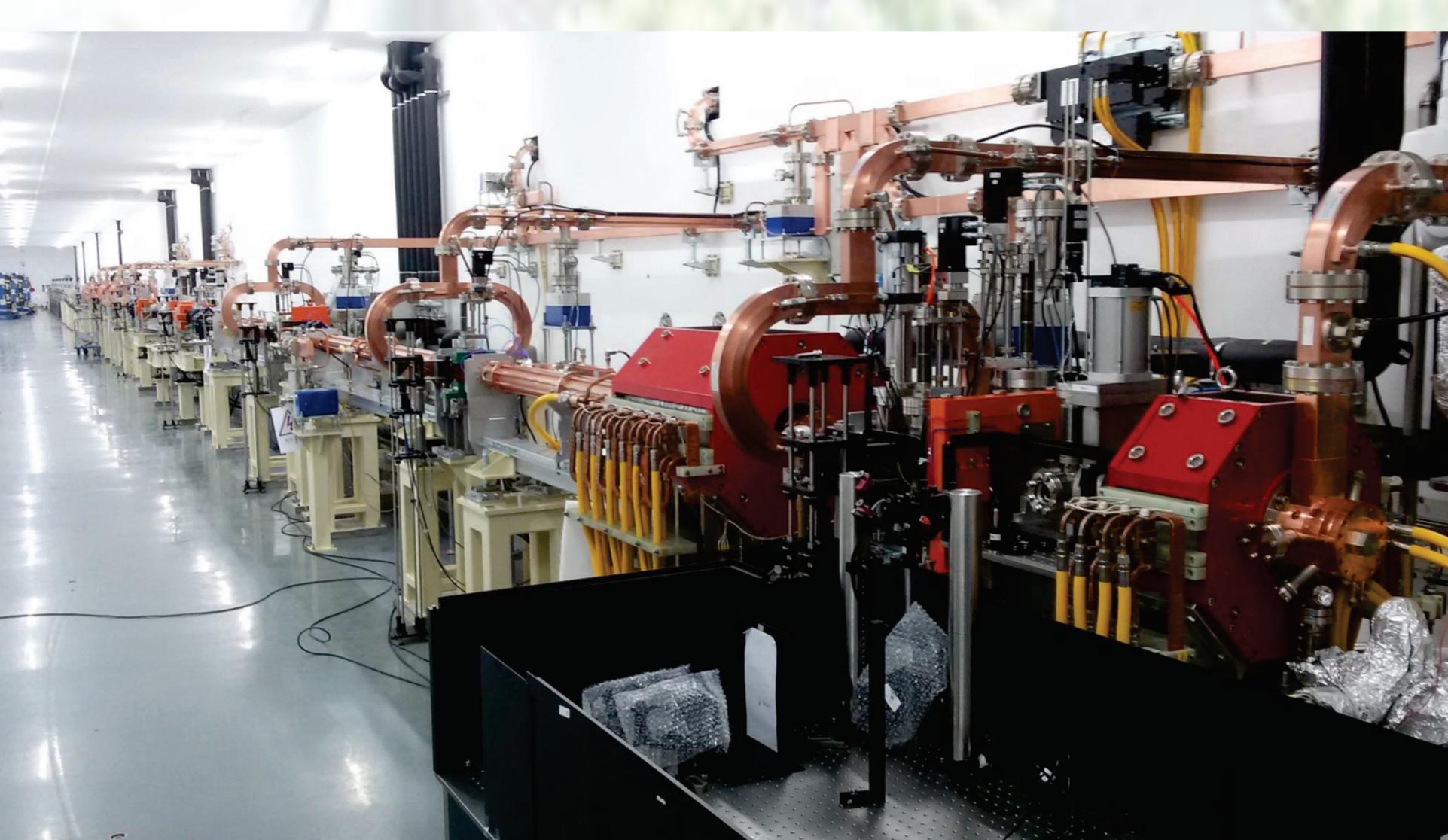
2009.12	SASE lasing
2010.12	HGHG saturation
2011.12	HGHG tunability
2012.04	Cascaded HGHG signal
2013.08	High harmonic EEHG
2013.11	Polarization control



## DCLS

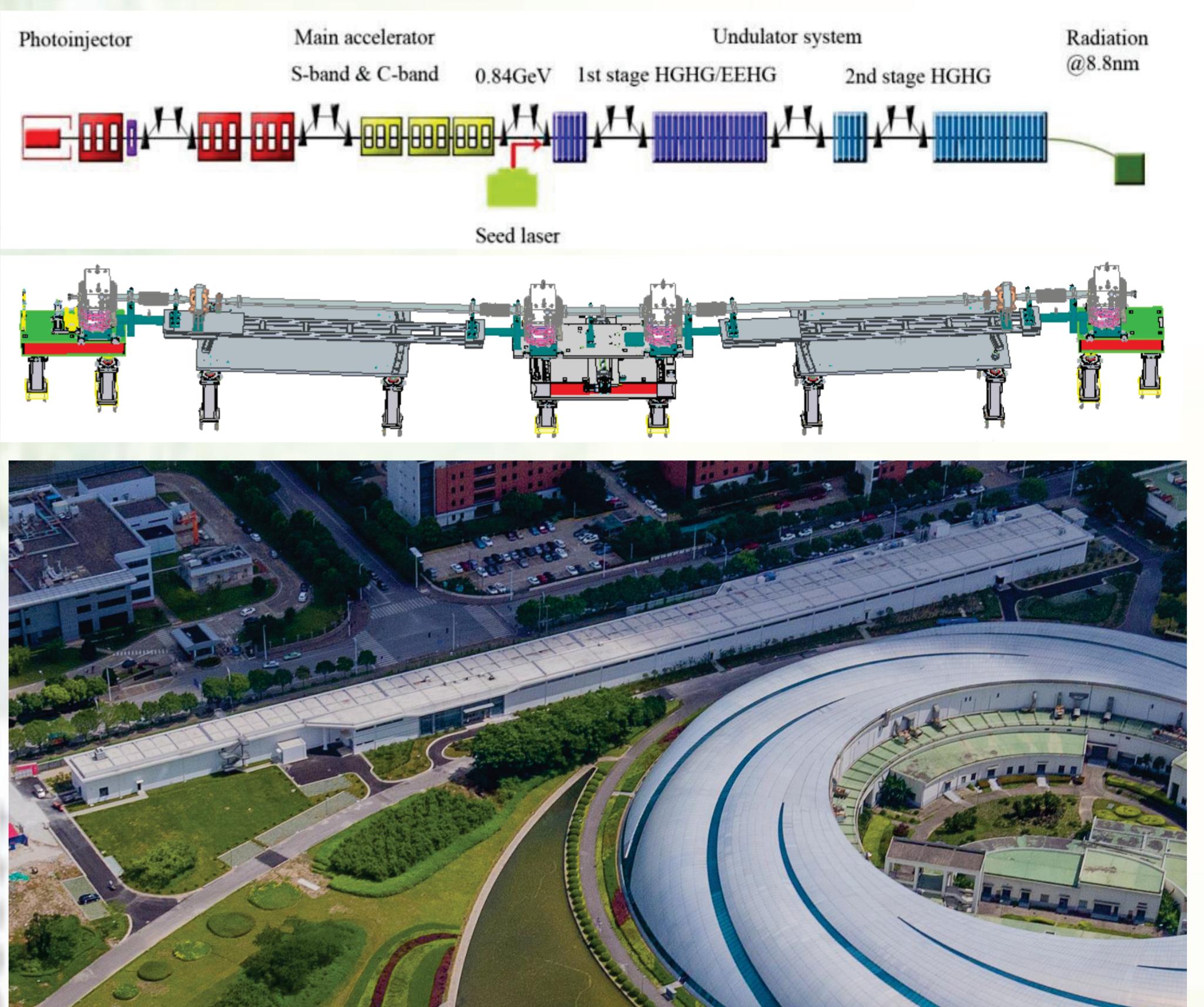
An user facility, based on the HGHG technique, developed jointly by DICP and SINAP at Dalian, will be operating exclusively in the EUV wavelength regime with full tunability. It is under commissioning and the first FEL radiation is expected in September.

Beam energy	300 MeV
Normalized emittance	1-2 mm.mrad
Bunch charge	500 pC
FEL wavelength	50-150 nm
FEL pulse energy	>100 μJ
Rep-rate	50 Hz



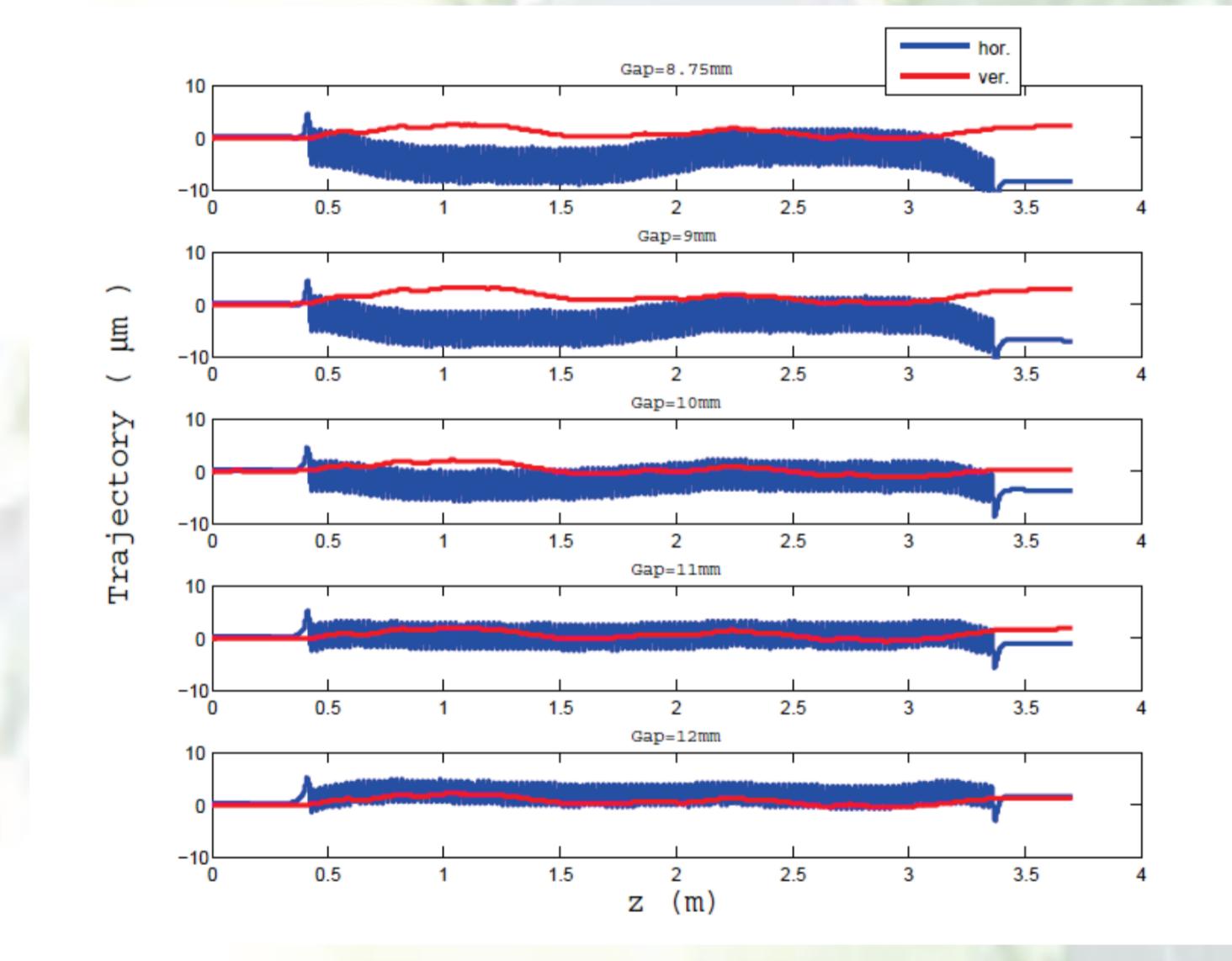
## SXFEL

Based on an 840MeV linac, aims at generating 8.8 nm FEL radiation with two-stage cascaded HGHG-HGHG and EEHG-HGHG schemes. It is an R&D prototype for future hard X-ray FEL, to explore the key FEL schemes and techniques. It has the potential to be upgrade to user facility. The commissioning is scheduled at the end of 2016.



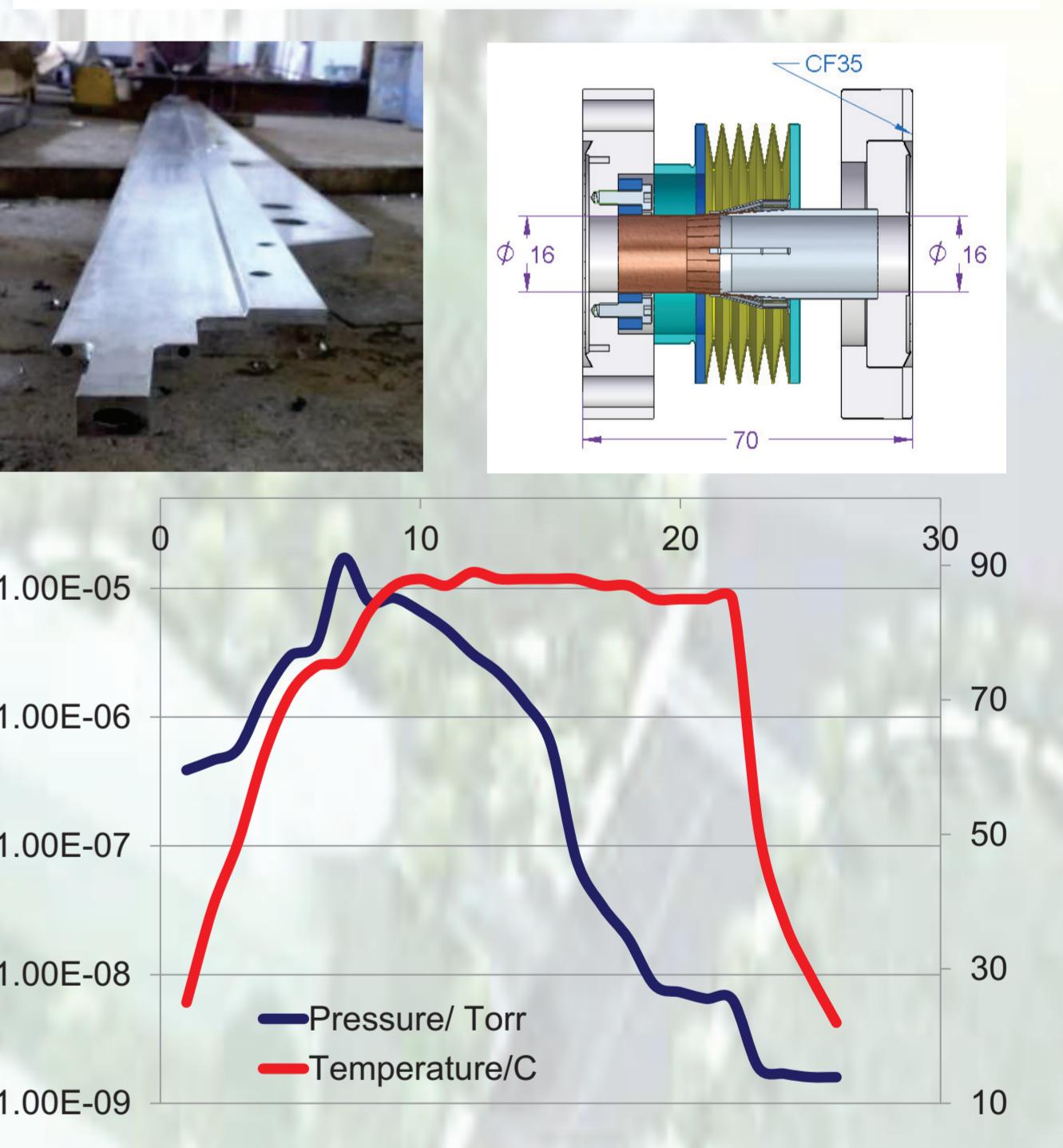
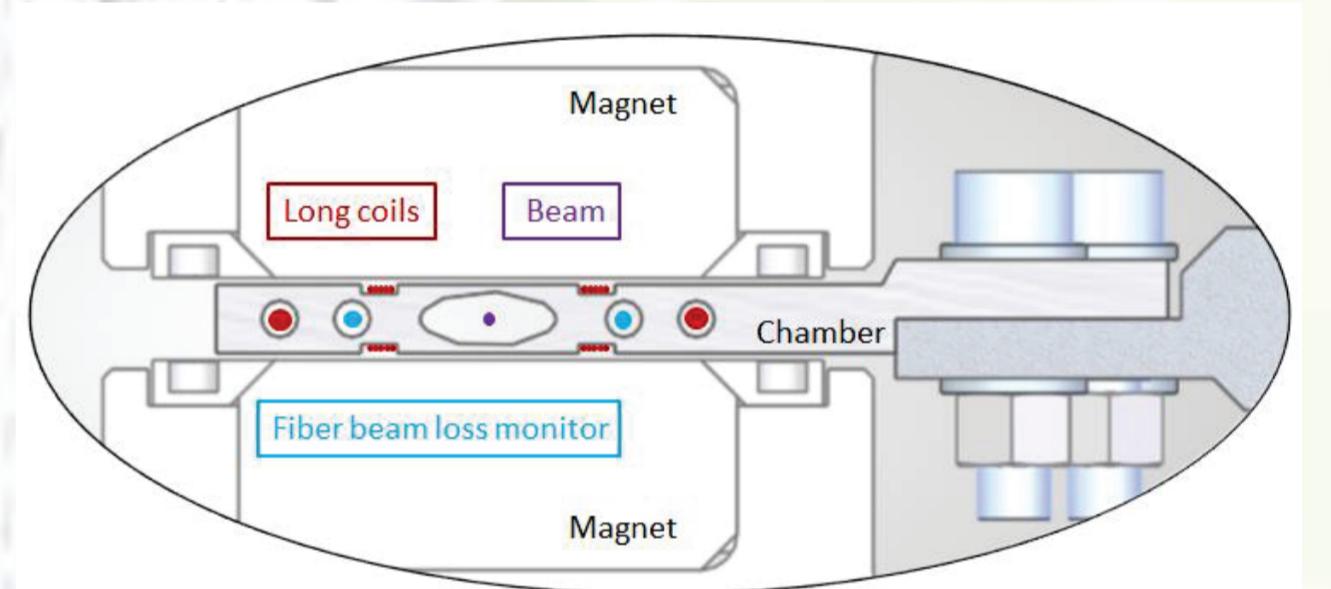
## UNDULATOR

Parameter	Specification	Measured
Minimum gap	8.75 mm	8.75 mm
Resolution of gap	< 5 μm	< 3 μm
Peak field	0.65 T	0.69T
R.M.S trajectory deviation	< 5 μm	< 3 μm
R.M.S phase error	< 5 °	< 5.3 °



## VACUUM CHAMBER

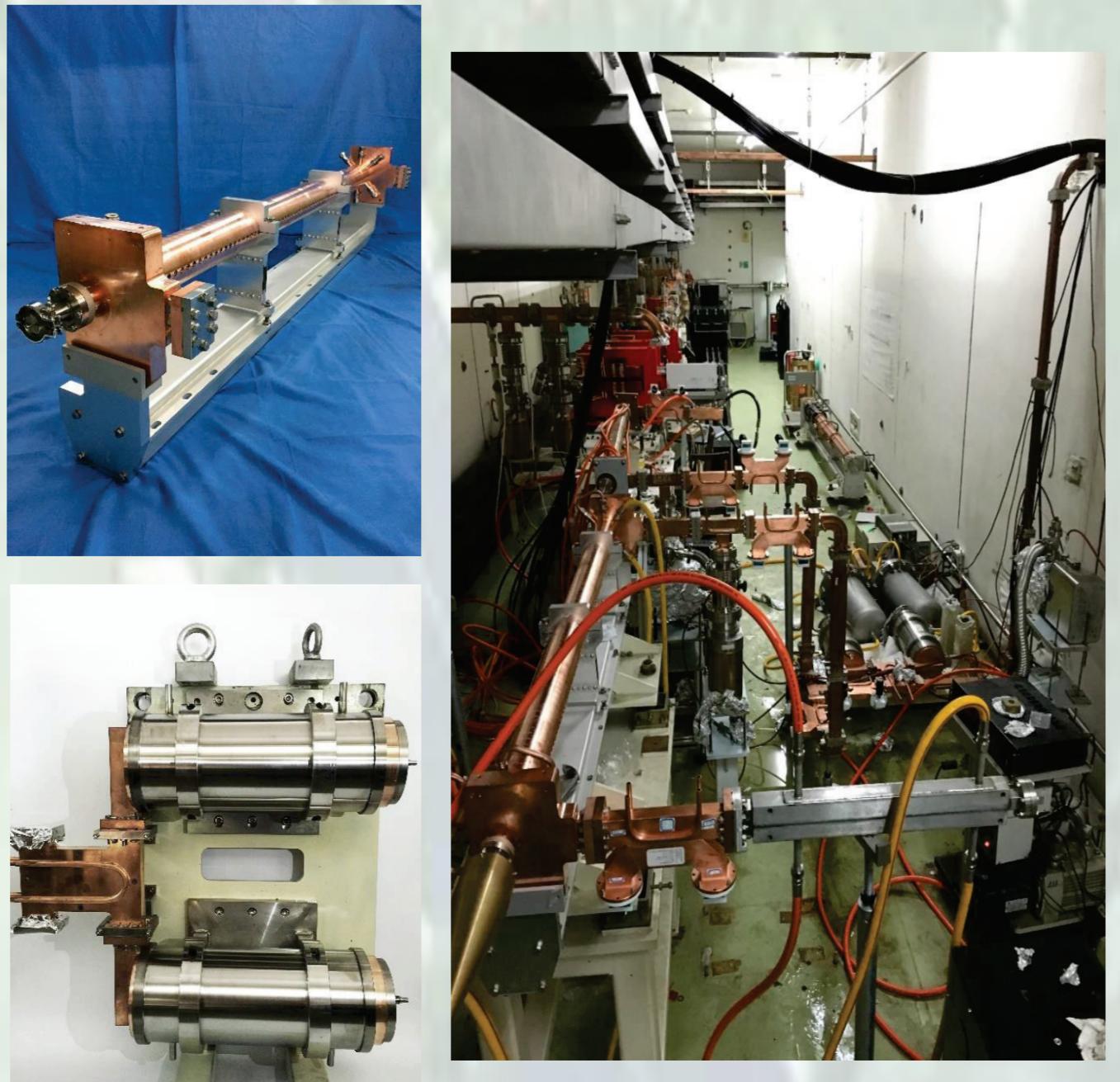
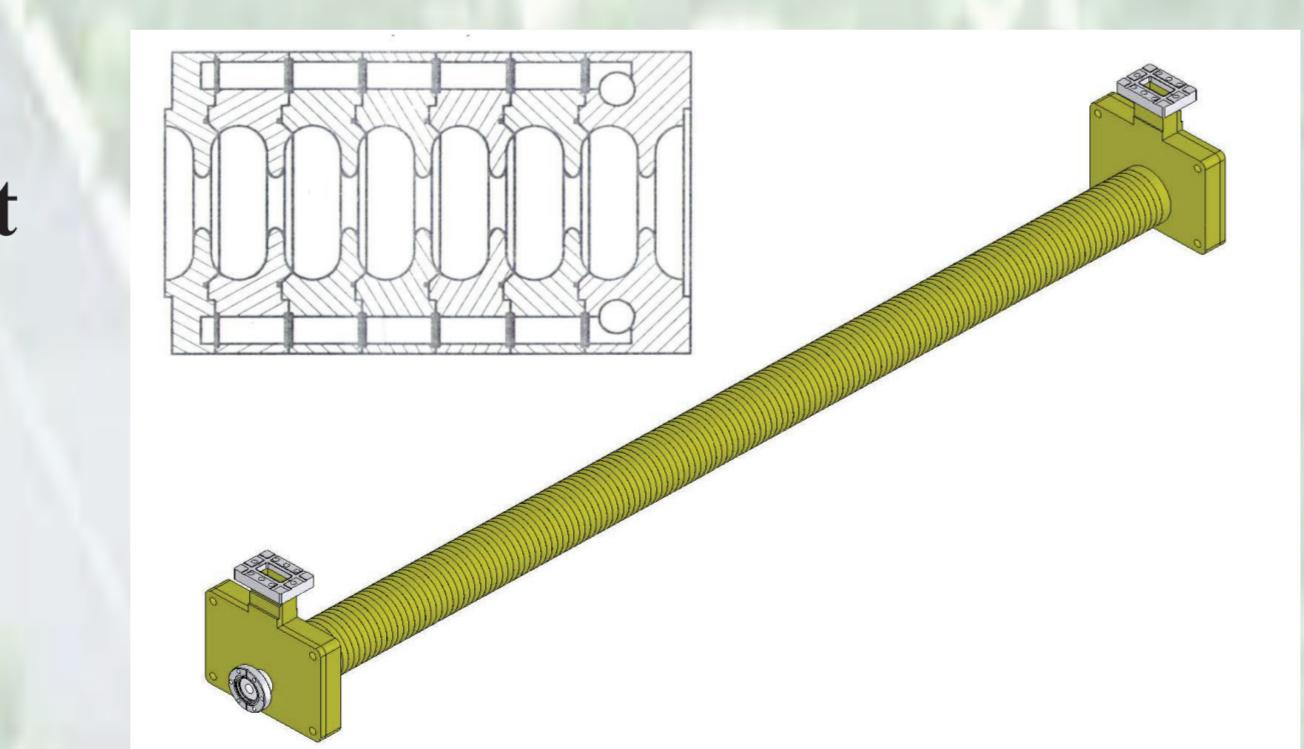
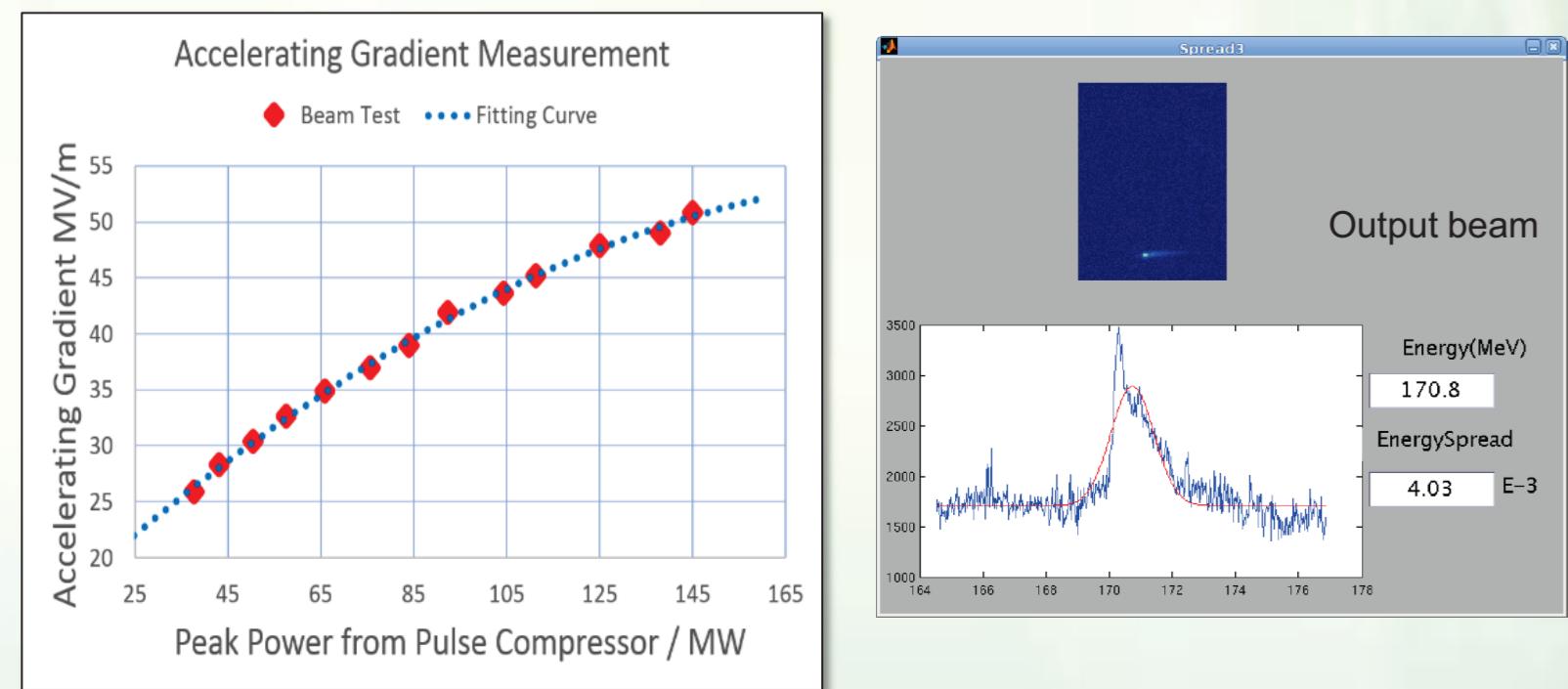
- A6063 extrusion chamber  
15mm × 6mm, δ0.75mm, L3.3m
- Surface roughness  $R_A \sim 200$  nm
- $P < 1 \times 10^{-6}$  Pa (after 90 °C bakeout)
- Flatness  $\sim 0.2$  mm



## C-BAND UNIT

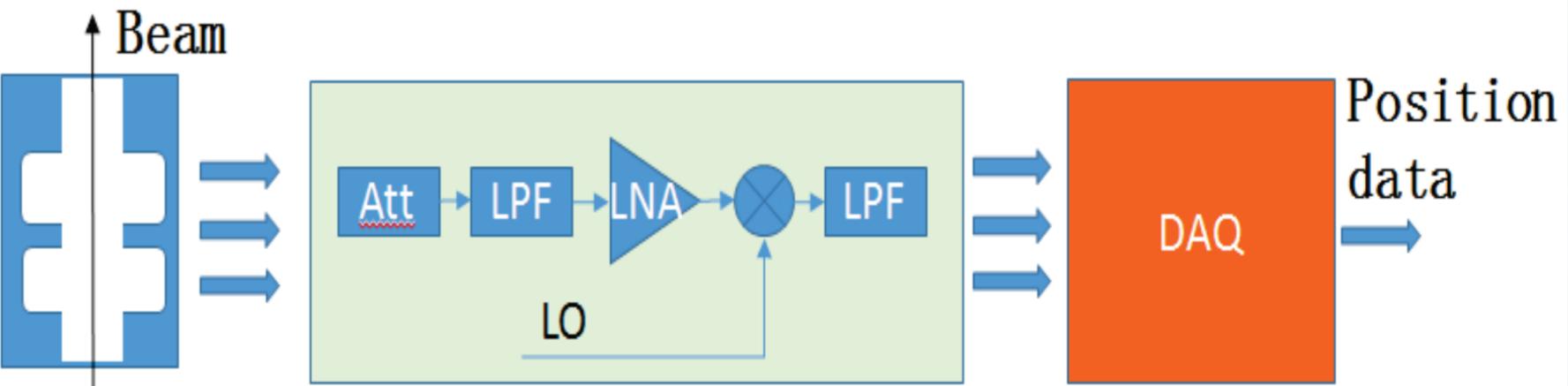
- Rounded cell, inner water cooling, compact coupler.
- High precise machining, Ag-Cu brazing.
- Final gradient reached 50.8 MV/m

Parameter	Design target	Test results
Operating mode	$4\pi/5$	$4\pi/5$
SWR	< 1.05@5712MHz	1.017@5712MHz
Accelerating gradient	40 MV/m	50.8 MV/m



## CBPM

- Reference cavity + position cavity.
- High precise machining, Ag-Cu brazing.
- Resolution is better than 1 μm @ 0.5 nC



Parameter	Frequency	Q value
Reference cavity	$4693 \pm 3$ MHz	$2230 \pm 10\%$
Position cavity (H)	$4680 \pm 3$ MHz	$4250 \pm 10\%$
Position cavity (V)	$4688 \pm 3$ MHz	$4250 \pm 10\%$

